

Title (en)  
METHOD FOR PRODUCING AN ELECTRIC STRIP

Title (de)  
VERFAHREN ZUR HERSTELLUNG EINES ELEKTROBANDS

Title (fr)  
PROCÉDÉ DE FABRICATION D'UN RUBAN ÉLECTRIQUE

Publication  
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Application  
**EP 21769633 A 20210818**

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Abstract (en)  
[origin: WO2022036382A1] The invention relates to a method for processing a silicon-containing, cold-rolled steel sheet, comprising a thermal treatment for producing a non-grain-oriented electric strip, wherein the steel sheet 2 contains between 1.5 and 6 wt.% of silicon, and wherein the steel sheet is moved in a strip-like state during the thermal treatment in a continuous process through an annealing installation having a preheating region, a hold region and a cooling region, the steel sheet being moved in the annealing installation in a vertical main conveying direction.

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